The 17th Chinese Lexical Semantics Workshop (CLSW 2016) was held during May 20–22, 2016, in Singapore, organized by the Chinese and Oriental Languages Information Processing Society (COLIPS) and Nanyang Technological University (NTU).

Since the first workshop in 2000, the Chinese Lexical Semantics Workshop (CLSW) has been held in different Asian cities, including Hong Kong, Beijing, Taipei, Singapore, Xiamen, Hsin Chu, Yantai, Suzhou, Wuhan, Zhengzhou, and Macao. Over the years, CLSW has become one of the most important venues for scholars to report and discuss the latest progress in Chinese lexical semantics and related fields, including theoretical linguistics, applied linguistics, computational linguistics, information processing, and computational lexicography. CLSW has significantly promoted academic research and application development in the fields.

CLSW 2016 received a total of 182 submissions. Each submission was reviewed by two to four independent expert reviewers. Finally, 94 papers were accepted with 62 scheduled as oral presentations and 32 scheduled as poster presentations in the workshop. The workshop also hosted five invited speeches. For this volume in Springer’s LNAI series, only 70 papers (38% of the total submissions) were selected. Among them, 50 are long papers and 20 are short papers. This book is organized in six topical sections: lexicon and morphology, the syntax-semantics interface, corpus and resource, natural language processing, case study of lexical semantics, and extended study and application.

As the editors of this volume, we would like to thank the conference chair, Advisory Committee members, Program Committee members, Publication Committee members, invited speakers, authors, and attendees for their contribution and participation. We would also like to thank the Organizing Committee members from COLIPS and NTU for their dedication in making the event a great success.

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